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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/534,411	05/11/2005	Michio Tsuyumoto	3273-0202PUS1	4477
DIRCH STEWART KOLASCH & BIRCH PO BOX 747 FALLS CHURCH, VA 22040-0747			EXAMINER	
			DESAI, ANISH P	
			ART UNIT	PAPER NUMBER
			1771	
SHORTENED STATUTOR	RY PERIOD OF RESPONSE	NOTIFICATION DATE	DELIVERY MODE	
3 MC	ONTHS	03/13/2007	ELECTRONIC	

Please find below and/or attached an Office communication concerning this application or proceeding.

If NO period for reply is specified above, the maximum statutory period will apply and will expire 6 MONTHS from the mailing date of this communication.

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mailroom@bskb.com

	Application No.	Applicant(s)					
Office Action Summers	10/534,411	TSUYUMOTO ET AL.					
Office Action Summary	Examiner	Art Unit					
	Anish Desai	1771					
The MAILING DATE of this communication ap Period for Reply	ppears on the cover sheet with the	correspondence address					
A SHORTENED STATUTORY PERIOD FOR REPL WHICHEVER IS LONGER, FROM THE MAILING [- Extensions of time may be available under the provisions of 37 CFR 1. after SIX (6) MONTHS from the mailing date of this communication If NO period for reply is specified above, the maximum statutory period Failure to reply within the set or extended period for reply will, by stature Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUNICATIO .136(a). In no event, however, may a reply be to d will apply and will expire SIX (6) MONTHS from te, cause the application to become ABANDON	N. mely filed n the mailing date of this communication. ED (35 U.S.C. § 133).					
Status							
1)⊠ Responsive to communication(s) filed on <u>08 l</u>	December 2006.						
	•						
3) Since this application is in condition for allows	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
closed in accordance with the practice under	closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims							
4)⊠ Claim(s) <u>1-5</u> is/are pending in the application.							
4a) Of the above claim(s) 1-3 is/are withdrawn	4a) Of the above claim(s) 1-3 is/are withdrawn from consideration.						
5) Claim(s) is/are allowed.							
6)⊠ Claim(s) <u>4 and 5</u> is/are rejected.							
7) Claim(s) is/are objected to.							
8) Claim(s) are subject to restriction and/	or election requirement.						
Application Papers	•						
9)☐ The specification is objected to by the Examin	ner.						
10)☐ The drawing(s) filed on is/are: a)☐ ac	cepted or b) objected to by the	Examiner.					
Applicant may not request that any objection to the	e drawing(s) be held in abeyance. Se	ee 37 CFR 1.85(a).					
Replacement drawing sheet(s) including the corre							
11)☐ The oath or declaration is objected to by the E	Examiner. Note the attached Offic	e Action or form PTO-152.					
Priority under 35 U.S.C. § 119							
12) Acknowledgment is made of a claim for foreig a) All b) Some * c) None of:	n priority under 35 U.S.C. § 119(a	a)-(d) or (f).					
1. Certified copies of the priority documents have been received.							
 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage 							
		ved in this National Stage					
application from the International Bures * See the attached detailed Office action for a lis	• • • • • • • • • • • • • • • • • • • •	rod .					
See the attached detailed Office action for a lis	st of the certified copies not receiv						
	•						
Attachment(s)							
1) Notice of References Cited (PTO-892)	4) Interview Summar	y (PTO-413)					
2) Notice of Draftsperson's Patent Drawing Review (PTO-948) Paper No(s)/Mail Date.							
3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date	5) Notice of Informal 6) Other:	r atent Application					

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The applicant's arguments in response to the Office action dated 09/08/06 have been fully considered.

1. Claims 1-5 are pending. Claims 1-3 are withdrawn. Support for newly amended claims 4 and 5 is found in the specification.

- 2. 112 rejections are withdrawn in view of the present amendment and response (pages 1-14 of 12/08/06 amendment).
- 3. 102/103-type rejections over Derwent abstract of JP 48-097774 are withdrawn in view of the present amendment and response (see pages 2-3 of 12/08/06 amendment). JP 48-097774 does not teach film-forming polymers as claimed.
- 4. 103-type rejections of Roy (US 3,929,971) in view of Kamide et al. (US 3,883,626) are withdrawn in view of the present amendment and response (see pages 2-3 of 12/08/06 amendment). Neither Roy nor Kamide teach film-forming polymers as claimed.
- 5. A new ground of rejection is made in view of Shigeru et al. (JP 2002-086476).

Claim Objections

6. Claims 4 and 5 are objected to because of the following informalities: the claim language of "average rate of surface hole area" is ambiguous and confusing because ordinarily the term "rate" is associated with "quantity X per time". Thus, the use of term "average **rate** of surface hold area" is ambiguous and confusing. For purpose of the examination the aforementioned language is interpreted as porosity.

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Claim Rejections - 35 USC § 102

The text of those sections of Title 35, U.S. Code not included in this action can be found in a prior Office action.

7. Claims 4 and 5 are rejected under 35 U.S.C. 102(b) as anticipated by Shigeru et al. (JP 2002-086476) (Machine translation provided by the examiner).

Regarding claim 4, the ratio of A/B is in the range of 0.3 to 3 and the ratio of C/D is in the range of 0.1 to 1.5 includes 1. Thus, any reference disclosing a **homogeneous** membrane wherein an average pore size of A of 0.01 to 10 μ m will read on claim 4. Similarly, regarding claim 5, the ratio of A¹/A² of 0.3 to 3 incorporates 1 and the ratio of C¹/C² of 0.7 to 1.5 incorporates 1. Thus, any reference disclosing a homogeneous membrane wherein an average pore size of 0.01 to 10 μ m and average porosity of 48% will read on the claimed ratio of A¹/A² and C¹/C².

Shigeru teaches a method and apparatus for forming a porous film. The porous film of Shigeru has homogeneous characteristics with respect to film thickness, pore size, voids, and pore shapes (abstract and 0041). According to Shigeru a porous membrane, which consists of polyimide precursor obtained in this invention is used as a polyimide precursor membrane (0031), which reads on a polymer component forming the film comprises at least one selected from a group of imide polymers as claimed. Additionally, the polyimide membrane of Shigeru has a thickness of 30 µm (0045). Further, Shigeru teaches that the porous membrane had a void content of 15 to 85% and average aperture (pore size) of 0.01 to 10 µm and the porous membrane with homogeneous porosity, aperture, and a void content makes it very useful in various

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applications (0041). With respect to claims 4 and 5, this, disclosure of Shigeru reads on average surface pore size A of 0.01 to 10 μ m (claim 4), average rate of surface hole area (porosity) C, average pore size B, and average rate of inside hole area (porosity) D. Additionally, since the membrane of Shigeru has homogeneous properties of pore diameter and void content (porosity), it meets the limitation of ratio of A/B in the range of 0.3 to 3 and ratio of C/D in the range of 0.7 to 1.5. Similarly, regarding claim 5 as previously noted, the porous membrane of Shigeru is homogeneous with respect to pore size and porosity wherein the membrane has pore size of 0.01 to 10 μ m and porosity of from 15 to 85%. Thus, the disclosure of Shigeru anticipates claims 4 and 5.

Response to Arguments

8. Applicant's arguments with respect to claims 4 and 5 have been considered but are most in view of the new ground(s) of rejection.

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Conclusion

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Anish Desai whose telephone number is 571-272-6467. The examiner can normally be reached on Monday-Friday, 8:00AM-4:30PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Terrel Morris can be reached on 571-272-1478. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

APD

ELIZABETH M. COLE
PRIMARY EXAMINER